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10/564,298	01/10/2006	Paulus Cornelis Duineveld	NL 03 0865 US1	7992
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PO BOX 3001			REDDY, SATHAVARAM I	
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			1794	
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			12/17/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary

Application No.	Applicant(s)	Applicant(s)		
10/564,298	DUINEVELD ET AL.	DUINEVELD ET AL.		
Examiner	Art Unit			
SATHAVARAM REDDY	1794			

	SAIR	AVARAINI REDDT	1/94	
Period f	The MAILING DATE of this communication appears on for Reply	the cover sheet with the c	correspondence ad	dress
WHIC - Exte afte - If No - Faile Any	HORTENED STATUTORY PERIOD FOR REPLY IS SE IIICHEVER IS LONGER, FROM THE MAILING DATE OF tensions of time may be available under the provisions of 3° CPR 1.35(a), in NO period for reply is specified above, the maximum statutory period wair apply a unitive to reply within the set or extended period for reply will, by statute, cause the try reply received by the Office later than three months after the maining date of the more planter than adjustment. See 3° CPR 1.70(b).	THIS COMMUNICATION to event, however, may a reply be tin and will expire SIX (6) MONTHS from a application to become ABANDONE	N. nely filed the mailing date of this o D (35 U.S.C. § 133).	,
Status				
2a)□	Responsive to communication(s) filed on This action is FINAL. 2b)⊠ This action Since this application is in condition for allowance exc closed in accordance with the practice under Ex parte	ept for formal matters, pro		e merits is
Disposit	ition of Claims			
5)□ 6)⊠ 7)□	Claim(s) 1-15 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from Claim(s) is/are allowed. Claim(s) 1-15 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or electic			
Applicat	ation Papers			
10)	The specification is objected to by the Examiner. The drawing(s) filed on is/are: a) □ accepted o Applicant may not request that any objection to the drawing Replacement drawing sheet(s) including the correction is re The oath or declaration is objected to by the Examiner	(s) be held in abeyance. See quired if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CF	
Priority	/ under 35 U.S.C. § 119			
a)	Acknowledgment is made of a claim for foreign priority a)	been received. been received in Applicati uments have been receive Rule 17.2(a)).	on No ed in this National	Stage

Attachment(s)

1) Notice of References Cited (PTO-892)

Notice of Draftsperson's Patent Drawing Review (PTO-948)
 Information Disclosure Statement(s) (PTO/S508)

Paper No(s)/Mail Date 1/10/2006.

Interview Summary (PTO-413)
 Paper No(s)/Mail Date. _____.

5) Notice of Informal Patent Application 6) Other: __

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DETAILED ACTION

Information Disclosure Statement

The information disclosure statement (IDS) submitted on 1/10/2006 has a
reference with an incorrect publication number US 2002/0041925. It should be US
2002/0041926 instead of US 2002/0041925. US 2002/0041925 has been stricken from
the IDS filed 1/10/2006 given that the applicants cited the wrong publication number and
2002/0041926 has been cited on the PTO-892.

Claim Objections

1. Claims 10, 13 and 15 are objected to under 37 CFR 1.75(c) as being in improper form because a multiple dependent claim can be dependent on only one set of claims, not more than one set of claims. See MPEP § 608.01(n). In the interest of compact prosecution, the claims are being treated as if they were properly dependent and examined as set forth below.

Claim Rejections - 35 USC § 112

- The following is a quotation of the second paragraph of 35 U.S.C. 112:
 - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 3. Claims 2-6, 8-9 and 11-12 are objected to by 35 U.S.C. 112, second paragraph because of a lack of proper antecedent basis. Claims 2-6 recites the limitation "An arrangement", claims 8-9 recites the limitation "A method", and claims 11-12 recites the limitation "A thin film device". In order for these dependent claims to have proper

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antecedent basis, it is suggested that "An arrangement" in claims 2-6 is changed to "The arrangement", "A method" in claims 8-9 is changed to "The method", and "A thin film device" in claims 11-12 is changed to "The thin film device".

4. Claim 14 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. The scope of the claim is confusing given that the claim is drawn to "a method" according to claim 12, however claim 12 is drawn to a thin film device, not a method.

Claim Rejections - 35 USC § 102

 The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- Claims 1-15 are rejected under 35 U.S.C. 102(b) as being anticipated by Miyashita et al (US 2002/0041926).

Regarding claim 1, Miyashita et al (US 2002/0041926) discloses a thin film patterning arrangement (Fig. 4) comprising a substrate (Fig. 4 #804), barriers (Fig. 4 #805 "banks") partitioning a surface of a substrate into sub-areas, the surface being of a

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polymeric material (paragraph [0042], lines 5-9; "plastic") and coated with a partly coated inorganic coating (Fig. 4 #801,802,803 "ITO transparent electrodes") (paragraph [0175] and paragraph [0176]).

Regarding claim 2, Miyashita et al (US 2002/0041926) discloses the inorganic coating comprising 100% inorganic coating (Fig. 4 #801,802,803 "ITO transparent electrodes"; paragraph [0175]).

Regarding claim 3, Miyashita et al (US 2002/0041926) discloses the inorganic coating comprising 5% inorganic coating (Fig. 4 #801,802,803 "ITO transparent electrodes"; paragraph [0175]).

Regarding claim 4, Miyashita et al (US 2002/0041926) discloses the inorganic coating comprising two separate coating materials (paragraph [0043], "composite film of indium oxide and zinc oxide").

Regarding claim 5, Miyashita et al (US 2002/0041926) discloses the surface treatment (paragraph [0200]). In regard to the difference in advancing contact angle of at least 10 degrees between an inorganic coating and the barriers, given that Miyashita et al (US 2002/0041926) discloses the thin film patterning arrangement identical to that presently claimed, that is subjected to the same surface treatment as that of the present invention (plasma treatment), it is clear that after such surface treatment a difference in

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advancing contact angle of at least 10 degrees between the surface of the inorganic coating an the surface of the barriers would inherently be established.

Regarding claim 6, Miyashita et al (US 2002/0041926) discloses an inorganic coating more than 70% transparent (Fig. 4 #801,802,803 "ITO transparent electrodes"; paragraph [0175])

Regarding claim 7, Miyashita et al (US 2002/0041926) discloses a method of producing a thin film patterning arrangement comprising supplying a substrate (Fig. 4 #804) with a surface of a polymeric material (paragraph [0042], lines 5-9; "plastic"), coating a substrate with a partly inorganic coating (Fig. 4 #801,802,803 "ITO transparent electrodes"), and depositing barriers on a coated surface (Fig. 4 #805 "banks") (paragraph [0175] and paragraph [0176]).

Regarding claim 8, Miyashita et al (US 2002/0041926) disclose subjecting the inorganic coating and barriers to surface treatment (paragraph [0200]).

Regarding claim 9, Miyashita et al (US 2002/0041926) discloses the surface treatment comprising plasma treatment (paragraph [0200]).

Regarding claim 10, Miyashita et al (US 2002/0041926) discloses a thin film device (organic EL element)comprising the thin film arrangement of claim 1 (Fig. 4) and

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thin film material (Fig. 4 #806, 807, 808) deposited onto the sub-areas (paragraph [0175], paragraph [0176]).

Regarding claim 11, Miyashita et al (US 2002/0041926) discloses the thin film device comprising an optical pattern (paragraph [0002]; paragraph [0007], lines 1-5; and paragraph [0024]). An optical pattern is a pattern where emission of light is used to emit another kind of light.

Regarding claim 12, Miyashita et al (US 2002/0041926) disclose the thin film pattern as an optical pattern and the device being a color filter. Given that Miyashita et al (US 2002/0041926) discloses the pattern is an optical pattern in that it uses emission of light, it is clear that Miyashita et al (US 2002/0041926) would inherently emit the light as color luminescence using luminescent layers (paragraph [0002][; paragraph [0007], lines 1-5; and paragraph [0024]).

Regarding claim 13, Miyashita et al (US 2002/0041926) discloses a method of producing a thin film device comprising providing a thin film patterning arrangement (Fig. 4) and depositing thin film material (Fig. 4 #806, 807, 808) onto the sub-areas (paragraph [0175], paragraph [0176]).

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Regarding claim 14, Miyashita et al (US 2002/0041926) discloses a method of depositing a thin film material (Fig. 4 #806, 807, 808) comprising ink jet printing of a liquid comprising the thin film material (paragraph [0176]).

Regarding claim 15, Miyashita et al (US 2002/0041926) discloses a display device comprising the thin film arrangement of claim 1, the thin film pattern arrangement obtained by claim 7, a thin film device of claim 10 and a thin film device obtained by claim 13 (paragraph [0024]; paragraph [0175]; paragraph [0176]; paragraph [0007], lines 1-5].

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to SATHAVARAM REDDY whose telephone number is (571) 270-7061. The examiner can normally be reached on 8:00 AM-5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Callie Shosho can be reached on (571) 272-1123. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

SIR

/Callie E. Shosho/ Supervisory Patent Examiner, Art Unit 1794